

Notice of References Cited

Application/Control No.

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Applicant(s)/Patent Under

Reexamination

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Art Unit

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U.S. PATENT DOCUMENTS

*	Document Number Country Code-Number-Kind Code	Date MM-YYYY	Name	Classification
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NON-PATENT DOCUMENTS

*	Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages)
U	Malik et al., "Polymer Structural Variation Towards Enhancing KrF Resist Lithographic Properties," Journal of Photopolymer Science and Technology, 1998, Vol. 11, No. 3, p. 431-438
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